<u>S/N 09/253,611</u> PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Paul A. Fairar

Examiner: Ron Pompey

Serial No.:

09/253,611

Group Art Unit: 2812

Filed:

February 19, 1999

Docket: 303.572US1

Title:

SELECTIVE DEPOSITION OF SOLDER BALL CONTACTS

RECEIVED

## INFORMATION DISCLOSURE STATEMENT

JAN 0 7 2004

Assistant Commissioner for Patents Washington, D.C. 20231

In compliance with the duty imposed by 37 C.F.R. § 1.56, and in accordance with 37 C.F.R. §§ 1.97 et. seq., the enclosed materials are brought to the attention of the Examiner for consideration in connection with the above-identified patent application. Applicant respectfully requests that this Information Disclosure Statement be entered and the documents listed on the attached Form 1449 be considered by the Examiner and made of record. Pursuant to the provisions of MPEP 609, Applicant further request that a copy of the 1449 form, initialled by the Examiner to indicate that all listed citations have been considered, be returned with the next official communication.

Under 37 C.F.R. §1.97(b)(3), it is believed that no fee or certificate is required with this Information Disclosure Statement.

The Examiner is invited to contact the Applicant's Representative at the below-listed telephone number if there are any questions regarding this communication.

Respectfully submitted,

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By his Representatives,

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CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail, in an envelope addressed to: Commissioner of Patents, Washington, D.C. 20231, on this 1740 day of January. 2002.

Amy Mor

Signature

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Form 1449* INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Usc several sheets if necessary)			Atty. Docket No.: 303.572US1 Serial N		Serial No	lo. 09/253,611	
			Applicant: Paul A. Farrar				
			Filing Date: February 19, 1999		Group: 2812		
Examiner			J.S. PATENT DOCUMENTS			Piling Date	
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Initial	Document Humber	Date	Country	Class	Subclass	Yes   No	
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Examiner	  Date Considered	
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\*Substitute Disclosure Statement Form [PTO-1449]

<sup>\*\*</sup>EXAMINER: Initia) if Citation considered, whether or not citation is in conformance with MPEP 605; Draw line through citation if not in conformance and not considered. Include copy of this torm with next communication to applicant.